

Title (en)  
Layered structure and process for producing a layered structure

Title (de)  
Schichtstruktur und Verfahren zur Herstellung einer Schichtstruktur

Title (fr)  
Structure stratifiée et procédé pour sa production

Publication  
**EP 1496140 A1 20050112 (DE)**

Application  
**EP 03015495 A 20030709**

Priority  
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Abstract (en)  
Layer structure (1) comprises a partially porous partially gas-permeable layer (7) arranged on a substrate (4). The porous layer has pores (10) delimited by walls (37) with a coating (40) formed on the walls. An independent claim is also included for a process for the production of the layer structure.

Abstract (de)  
Schichtstrukturen nach dem Stand der Technik weisen eine nicht so effiziente Kühlung gegen ein äußeres heißes Gas auf. Die erfindungsgemäß ausgebildete Schichtstruktur (1) weist neben einer porösen Schicht (7) zumindest teilweise eine Beschichtung (40) innerhalb der Schicht (7) auf. Somit wird die Kühlung und der Schutz vor zu hohem Wärmeeintrag in die Schichtstruktur (1) verbessert. <IMAGE>

IPC 1-7  
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IPC 8 full level  
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